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Caesium Fluoroxysulphate as a Mild Fluorinating Agent for the Fluorination of Alkoxy-substituted Benzene and Naphthalene Derivatives

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Summary Room-temperature fluorination of alkoxysubstituted benzene derivatives with caesium fluoroxysulphate in the presence of boron trifluoride as catalyst resulted in the formation of ortho- and para-fluorosubstituted products, the ratio being dependent on the size of the alkoxy-group, while reactions with 2-alkoxynaphthalene derivatives resulted in the formation of 1,1difluoro-2-oxo-1,2-dihydronaphthalene as well as 1-fluorosubstituted products.

INTRODUCTION of fluorine into aromatic molecules is a different problem from the introduction of other halogen atoms. 1 CF₃OF² and xenon difluoride³ are the only mild reagents so far discovered for the direct introduction of fluorine into organic molecules. The high price of xenon difluoride is its greatest disadvantage, while reactions with CF₃OF proceed successfully only with alkoxy-substituted aromatic molecules, with the experimental conditions demanding stringent safety precautions because of the high toxicity of the reagent gas and its extreme reactivity. The recent preparation and characterisation of caesium and rubidium fluoroxysulphates,4 and their oxidative properties and stability at room temperature made them promising as mild fluorinating agents for organic substrates. However, reaction with toluene in aqueous solution resulted in a complex reaction mixture,4 which appeared to diminish their potential utility.

We now report that caesium fluoroxysulphate is an easily handled, mild fluorinating agent for alkoxy-substituted benzene and naphthalene derivatives.† In a typical experiment, carried out in a polyethylene vessel, to a stirred suspension of CsSO₄F (1 mmol) in acetonitrile (3 ml), a solution of the aromatic substrate (1 mmol) in acetonitrile (1 ml) was added, and finally a catalytic amount of BF3 was introduced over the reaction mixture. The mixture was stirred at room temperature for 1.5-6 h, 10 ml of methylene dichloride was added, the unsoluble product filtered off, and the filtrate was washed with water and dried (Na₂SO₄). The solvent was evaporated off in vacuo, the mixture was analysed by ¹⁹F n.m.r. spectroscopy and the products were isolated by gas chromatography. Reaction with phenol (Scheme) gave 70% of 2- and 4-fluorophenol and 30% of unchanged phenol. Conversion of starting material into products was improved by increasing the amount of caesium fluoroxysulphate from 1 mmol to 1.2 mmol. The yields of fluoro-products were higher, but small amounts of difluoro-phenols were also formed (up to 8%). We have also studied the effect of the alkoxy group on the course of fluorination and found that

OR
$$CsSO_4F$$
 OR F + F

(1)

R Ratio (1): (2)^a

H 6:2:1

Me 2:8:1

Bu^a 1:8:1

EtCHMe 1:2:1

a Ratios determined by ¹⁹F n.m.r. spectroscopy; total yields 70-80%.

R	Ratio (3): (4)
H	83:17
Me	74:26
Et	72:28
Pri	62:38

Ratios determined by 19F n.m.r. spectroscopy; total yields 60-80%.

SCHEME.

the amounts of the para-isomers are increased with larger substituents (Scheme). In no case did we find evidence for the formation of meta-products, and the yields of monofluoro-substituted products were between 70 and 80%.

Reaction with β -naphthol resulted in the formation of two products (3) and (4), (3) being the main product. The alkoxy group has an important affect on the amount of the ketone (4) which is formed (Scheme). The yields of products are also very high (60-80%).

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† CsSO₄F is stable when stored in a dry polyethylene flask at 0 °C, while on contact with a metallic spatula or under mechanical pressure decomposition or even explosion takes place.

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